Construction of transferable spherically-averaged electron potentials

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Abstract

A new scheme for constructing approximate e ective electron potentials within density-functional theory is proposed. The scheme consists of calculating the e ective potential for a series of reference system s, and then using these potentials to construct the potential of a general system. To make contact to the reference system the neutral-sphere radius of each atom is used. The scheme can simplify calculations with partial wave methods in the atom ic-sphere or mu n-tin approximation, since potential parameters can be precalculated and then for a general system obtained through simple interpolation form ulas. We have applied the scheme to construct electron potentials of phonons, surfaces, and di erent crystal structures of silicon and alum inum atom s, and found excellent agreem ent with the self-consistent e ective potential. By using an approximate total electron density obtained from a superposition of atom -based densities, the energy zero of the corresponding e ective potential can be found and the energy shifts in the m ean potential between inequivalent atom s can therefore be directly estim ated. This approach is shown to work well for surfaces and phonons of silicon.

O ne route that seems promising in order to construct computationally e cient 'ab initio' schemes for calculating total energies and forces of solids is to exploit the variational properties of density-functional theory [1]. We have shown earlier how the total electron density can be decomposed into a superposition of transferable atom-based densities for metals and sem iconductors [2,3]. When such densities are used to generate an input density for the Harris functional [4,5], excellent total energies are obtained for surfaces, phonons and structural di erences [6,3] due to the fact that the Harris functional is stationary in the density. In this way the self-consistency loop is avoided. It is the purpose of the present report to show how the the variational nature of density-functional theory can be exploited even further by working with both approxim ate densities and potentials simultaneously.

The H ohenberg-K ohn density functional can be generalized to a functional [n;v] which depends on both the density n and the potential [5,7] and which is stationary with respect to independent variations of the density and the potential. The general functional can be written

$$E[h;v] = \begin{bmatrix} X & Z \\ [v] & n(r)v(r)dr + E_{el}[h] + E_{xc}[h]; \qquad (1)$$

where denotes the eigenvalues generated by the potential v, and where $E_{el}[n]$ and $E_{xc}[n]$ is the electrostatic and exchange-correlation energy functionals, respectively. If the potential is restricted to be a functional of the density, the Hohenberg-Kohn functional or the Harris functional appear as special cases [7]. The stationary property of the general functional with respect to variations in the potential can be utilized to construct e cient schemes for evaluation of total energies and $H \in M$ an $F \in M$ an $F \in M$. In the following we shall describe one such scheme which has its root in the e ective-medium theory [7]. The scheme applies to situations in which the kinetic energy can be calculated within the mun-tin or atom ic-sphere approximation (ASA) with spherically-symmetric potentials within the atom ic spheres. The idea is to use self-consistently calculated potentials from a series of reference system s which we choose here to be a bulk crystal with varying lattice constant. For a given atom in a general system the potential within the atom ic sphere around the atom is then approximated by the potential in the reference system with an appropriate lattice constant. The lattice constant of the associated reference system is determined by the requirem ent that a neutral sphere around the atom should have the same radius in the system under study and in the reference system.

The neutral-sphere is a sphere containing 3 (4) electrons in the case of alum inum (silicon) in the pseudo-potential scheme. If the approach described here is combined with the density construction of Ref. [2] where the total electron density, n (r), is approximated by a superposition of atom-based densities, n_{atom}, positioned at each atom ic site, R_i,

$$n(\mathbf{r}) = \sum_{i}^{X} n_{atom} (\dot{\mathbf{r}} R_{i}); \qquad (2)$$

then the NS radius can be obtained directly, or simple interpolation form ulas can be made from which the NS radius can be obtained with high accuracy [6,3].

We have used this scheme to calculate the elective potential of silicon and alum inum atom s in dimensions. For silicon we use the diam ond structure and for alum inum the foc structure as reference systems. The lattice parameter is regarded as a parameter which can be varied in order to india good approximation for the potential. To calculate the elective potentials we use a self-consistent plane-wave pseudo-potential program, with a 12 Rydberg cuto for the plane-wave basis set. With this cuto, we get the lowest energy con guration of silicon to be the diam ond lattice with lattice constant 10.17 a_0 , and for alum inum the foc lattice with lattice constant 7.48 a_0 .

As test systems for silicon we consider the diam ond longitudinal phonon at the X point (denoted LAO (X) and frozen at the displacement 0.02 in units of the lattice constant), the diam ond (100) surface, and the fcc structure with a lattice constant of 7.18 a_0 . And sim ilarly for alum inum, we use the fcc longitudinal phonon at the X point (denoted L (X) and displacement 0.02), the fcc (100) surface, and the diam ond structure with a lattice constant of 11.05 a_0 . These six structures cover the two elements in quite di erent surroundings, and if the potential construction works for these situations a high degree of transferability is guaranteed.

As the st test system, we consider silicon in the fcc structure. As noted in the introduction the way we make contact between the test system and the reference system is through the neutral-sphere (NS) radius. In the fcc structure the NS radius is almost equal to the W igner-Seitz (WS) radius, while the NS radius is substantially smaller than the WS radius in the diam ond structure. This di erence is due to the large regions in the diam ond lattice which contain almost no charge and therefore are not included in the neutral sphere. In Fig. 1 we show the local part of the self-consistent elective potential of the fcc test system compared to that of the reference system with the same NS and WS radius as the fcc test system, respectively. Clearly the potential of the reference system chosen according to the NS criterion gives by far the best approximation to the fcc potential.

In order to quantify the di erence in the potentials, we introduce the rm s. error $\ ,$ de ned by

$${}^{2} = \frac{3}{s_{w}^{3}} \int_{0}^{z} s_{w} \left[v(\mathbf{r}) - v^{\text{ref}}(\mathbf{r}) \right]^{2} r^{2} d\mathbf{r};$$
(3)

where s_w is the W S radius of the test system, and the two potentials are aligned such that they have the same average within the sphere. To get an estimate of the error in the potentials due to the nite plane-wave basis set, we have compared one of the reference potentials of silicon with that of an 18 Rydberg calculation. We nd a rm s. error of = 0.06 eV, so this is the level of accuracy we ideally can obtain.

In Fig. 2 we show the rm s error between the potential of the fcc test system and the diam ond reference system as a function of the W S radius (i.e. as a function of lattice constant) of the diam ond lattice. We see that optim ally the reference system should be chosen with a W S radius of 3.18 a_0 . We note that this is not at all close to the W S radius in the fcc test system ($s_w = 2.806 a_0$). In the ASA the reference diam ond structure is often embedded in a bcc structure with twice the number of spheres where only half of them contain an atom, and the others are empty. For this construction the sphere radius is a factor $2^{1=3}$ sm aller than the W S radius, and the reference system where this sm aller sphere equals the fcc W S radius is given by $s_w = 3.53 a_0$, which still is far from the the optim al reference system , has a W S radius of 3.178 a_0 , and is therefore alm ost exact the optim al reference system. This is not just a coincidence, since for all test system s investigated we have found this to be the case.

In Table 1 we show the m inim alrm s. error between the potential of the six test system s and the reference system, compared to the error when the reference system is chosen to have the same NS radius or the same WS radius as the test system. It is evident from the table that using the reference potential chosen according to the NS criterion is almost optim al, while the WS criterion is far from optim al. It should be noted that if the integral in Eq. (2) were done within the neutral sphere instead of within the WS sphere, the NS criterion would give even sm aller errors.

In order to estim ate how much the errors induced by the approxim ations for the potential will a ect the total energy, we show in Table 2 the value of LM TO potential parameters [8] for the three potentials of Fig. 1. The potential parameters are calculated by solving the radial Schrödinger equation at a xed energy for the s and p angular component (= f13:22;18:96g), with the energy chosen at the center of gravity of the occupied part of the fcc band. The accuracy of the potential parameters directly re ects the accuracy of the corresponding one-electron bands, and thereby the one-electron band energy. A s seen from

Table 2 the potential parameters obtained with the NS criterion are in excellent agreement with the self-consistent parameters, while the potential parameters obtained with the WS criterion are more than 10 percent \circ .

Until now we have aligned the average potentials within the W S sphere. However, for a surface calculation the mean potential at the surface is shifted relative to the bulk and we need to describe this shift in order to get a good estimate of the overall potential. At rst sight the problem seems hard to overcome since the mean potential is arbitrary for a bulk calculation due to the divergence of the electrostatic potential [9]. However it is possible to circum vent this problem if we use the potential constructed from a superposition of atom -based densities. W e will name this potential the Harris potential since this is the e ective potential used in the Harris functional, when the input density is obtained from a superposition of atom -based densities. W e know from previous studies that when this potential is used as an input to the Harris functional, excellent total energies are obtained for phonons, surfaces, and di erent crystal structures [2,6].

The electrostatic part of the Harris potential $V_{el}^{H arris}$ can in a natural way be divided into a sum over atom -based electrostatic potentials $v_{el}(r)$ each given by the sum of one ionic potential v_{ion} and the Hartree potential derived from one atom -based density n_{atom}

$$V_{el}(\mathbf{r}) = \sum_{i}^{X} V_{el}(\mathbf{j}\mathbf{r} \quad \mathbf{R}_{i}\mathbf{j}) = \sum_{i}^{X} (v_{ion}(\mathbf{j}\mathbf{r} \quad \mathbf{R}_{i}\mathbf{j}) + \frac{n_{atom}(\mathbf{j}\mathbf{r}^{0} \quad \mathbf{R}_{i}\mathbf{j})}{\mathbf{j}\mathbf{r} \quad \mathbf{r}^{0}\mathbf{j}} d\mathbf{r}^{0}):$$
(4)

W ith this construction the 1/r divergence of the electrostatic potential is avoided, since the atom -based density decreases exponentially, and thereby xes the vacuum level. Note that a consequence of this is that within this approximation all surfaces of a solid will have the same work function. In contrast to the total energy the work function is not variational in the density, and we cannot expect the density ansatz Eq. (3) to produce an accurate estimate.

Having established a common energy zero for all Harris potentials we can now proceed to determ ine the energy shifts of the mean potential for atom s in dierent environments. In Fig. 3 the solid curve indicates the mean Harris potential for silicon in the reference diam ond structure as a function of the NS radius. A loo shown are the actual shifts of both the Harris and the self-consistent potential at the three principal surfaces and the potential shifts of the two inequivalent atoms in the LAO (X) phonon. These potential shifts are marked in the gure at the calculated NS radii of the atom s. We see that the potential shift in the reference system compares surprisingly well to the potential shifts in the test system s. On the average, the shift of the Harris potential is about 4 percent higher than for the selfconsistent potential, and the shift of the reference system is about 8 percent higher than for the Harris potential.

In Table 3 we show the rm s. enor between the Harris potential and the self-consistent potential for a silicon atom at the diam ond (100) surface. This is compared to the rm s error between the self-consistent surface potential and both the self-consistent and Harris potential of the reference system when the reference system is chosen according to the NS criterion. As seen from the table the rm s errors are similar for the three potentials, and since the total energies obtained using the Harris potential are excellent [6,3], all three reference potentials are accurate enough to be used to calculate total energies.

In summary we have presented a scheme for obtaining transferable ASA potentials. The scheme was applied to six test systems consisting of silicon or alum inum atoms. The obtained potentials were in very good agreem ent with the actual self-consistent potentials, reproducing both the radial variations and the shifts in the mean potential, and when used as input to the LM TO method accurate potential parameters were obtained. We expect the method to be valuable for constructing new approximate total energy schemes, and it is presently used in a new formulation of an E ective-M edium Tight-B inding model for Silicon [3].

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REFERENCES

- [1] P. Hohenberg and W. Kohn, Phys. Rev. 136, 3864 (1964), W. Kohn and L. J. Sham, Phys. Rev. 140 (4A), A1133 (1965).
- [2] N. Chetty, K. W. Jacobsen and J. K. N rskov, Lett. J. Phys., Condens. M atter 3, 5437 (1991).
- [3] K. Stokbro, N. Chetty, K. W. Jacobsen, and J. K. N. rskov, to be published.
- [4] J. Harris, Phys. Rev. B31 (4), 1770 (1985).
- [5] W M C. Foulkes and R. Haydock, Phys. Rev. B39 (17), 12520 (1989).
- [6] N. Chetty, K. Stokbro, K. W. Jacobsen, and J. K. N rskov, Phys. Rev. B 46, 3798 (1992). K. Stokbro, N. Chetty, K. W. Jacobsen, and J. K. N rskov, Proceedings of the 15th Tanigushi sym posium, (Springer 1993).
- [7] K.W. Jacobsen, J.K.N rskov and M.J.Puska, Phys. Rev. B35 (14), 7423 (1987).
- [8] O.K. Andersen, O. Jepsen, and M. Sob, in Electronic Bandstructure and its applications, edited by M.Yussou (Springer Lecture Notes, 1987). Mu n T in Orbitals and Electronic Structure by H.L.Skriver, Springer-Verlag (1984).
- [9] L.K leinm an, Phys Rev. B24 (12), 7412 (1981).

FIGURES

FIG.1. The gure shows the self-consistent e ective potential (i.e. fv(r)) of silicon in the fcc structure (solid line) and that of the diam ond reference system with the same NS radius (dotted line) and W S radius (dashed line), as a function of the radial distance The potentials have been aligned such that the mean potential within the W S sphere is zero. The two vertical lines show the NS and W S radius of the fcc system, respectively.

FIG.2. The gure shows the rm s error (Eq. (2)) between the elective potential of silicon in the fcc structure and the potential in the diam ond reference system as a function of the W S radius of the reference system .The three crosses show the error when the reference system has the sam e W S radius, N S radius and bcc W S radius (diam ond with empty spheres) as the fcc system, respectively.

FIG.3. The solid curve shows the mean Harris potential, within the NS, of the diam ond reference system as a function of the NS radius. The two rst crosses show the shift in the mean Harris potential for the two inequivalent atoms in the LAO (X) phonon, at their NS radii. The last three crosses show the shift in the mean potential at the diam ond (111), (110), and (100) surface, respectively. The circles show the shifts for the corresponding self-consistent potentials. The dotted line shows the mean potential in the equilibrium diam ond lattice.

TABLES

potential	C _p C _s [eV]	s [eV]	p [eV]
SC fcc	10.968	1,566	1.358
ref.NS	10.961	1,565	1.355
ref.WS	13.028	1.786	1.432

TABLE I. Calculated LM TO potential parameters for the three pseudopotentials of Fig. 1. For each angular component the appropriate nonlocal contribution to the potential has been added.

TABLE II. The strow shows the minimal rms. error between the potentials of the six test systems and the reference system. The second and third row show the rms. error when the reference system is that with the same NS and WS radius as the test system, respectively. The

rst three columns show the errors for the three silicon test systems; the fcc structure, the (100) diam ond surface, the diam ond longitudinal phonon at the X point (LAO (X)) with a displacement of 0.02 in units of the lattice constant. The last three columns show the errors for the three alum inum test systems; The diam ond structure, the fcc (100) surface, and the fcc longitudinal phonon at the X point (L (X)) with displacement 0.02 in units of the lattice constant.

	Silicon			A lum inum		
	FCC	(100)	LAO(X)	D iam on	d (100)	L(X)
^{m in} (eV)	0.15	80.0	0.06	0.11	0.05	0.028
^{NS} (eV)	0.15	0.20	0.08	0.24	0.10	0.034
^{w s} (eV)	1.49	1.22	0.34	0.89	0.48	0.042

TABLE III. The rm s. error of potential di erences (Eq. (2)) for a silicon atom at the (100) surface. The di erences are between the self-consistent surface potential V^{SC} , the Harris potential $V^{H \ arris}$ for the surface with the density construction Eq. (3), and the analogous potentials in the diam ond reference system chosen according to the neutral sphere (NS) criterion.

	$V^{SC} = V^{H arris}$	V ^{SC} V ^{SC} _{ref}	$V^{SC} = V_{ref}^{Harris}$
^{NS} (eV)	0.24	0.20	0.30





